

METHOD FOR FORMING A JUNCTION REGION OF A SEMICONDUCTOR DEVICE

Inventor: Yu-Kun CHEN

Docket No. 4425-344

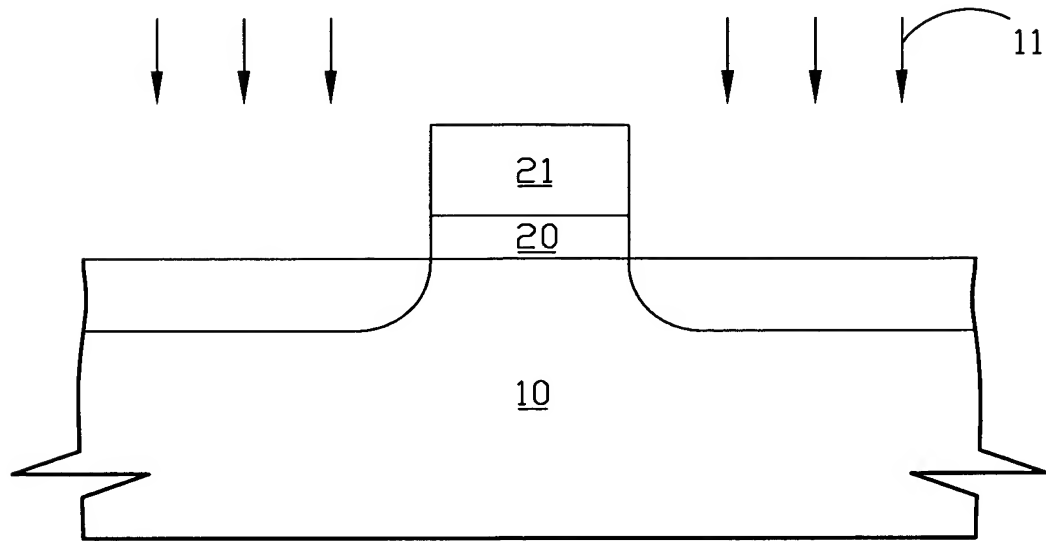


FIG.1A

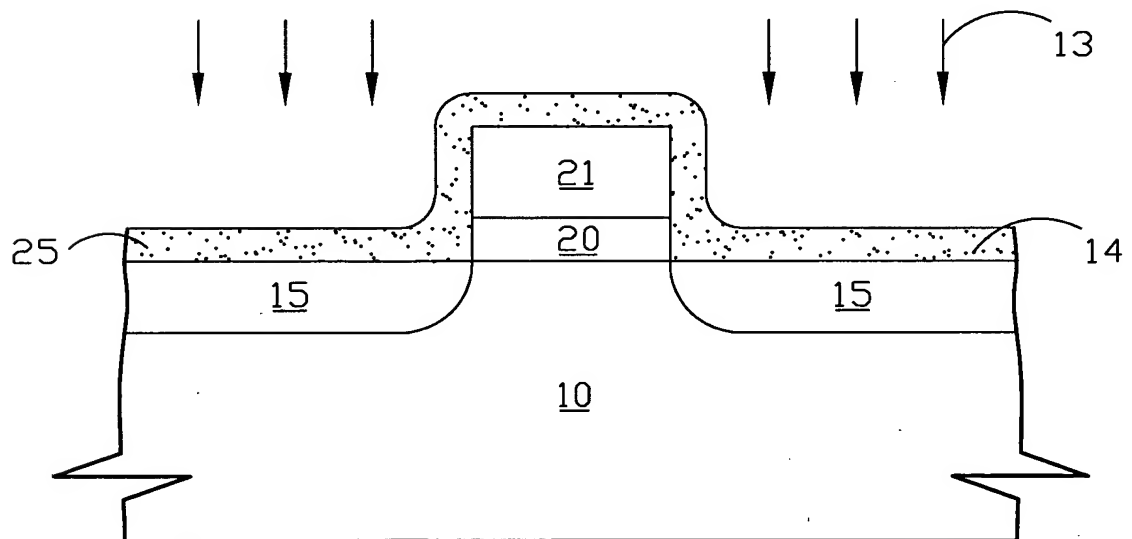


FIG.1B

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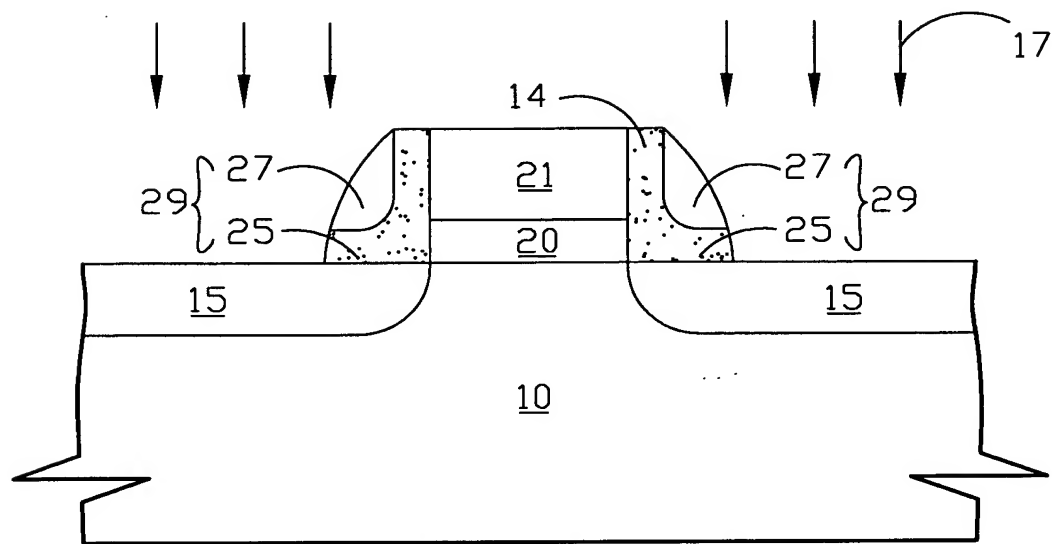


FIG. 1C

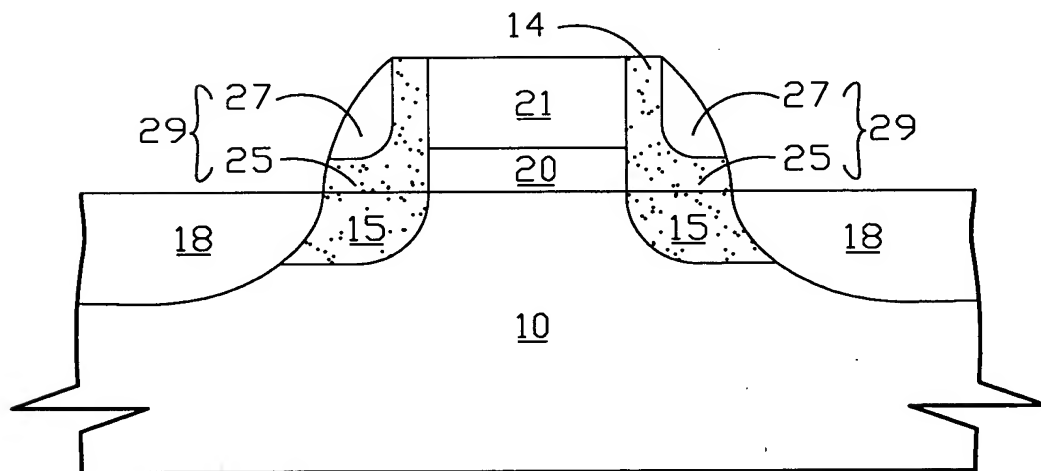


FIG. 1D

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